

IFW



PATENT  
30205/37328A

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Min Ho Jung, et al.

) I hereby certify that this document  
referred to as enclosed herewith is being  
deposited with the United States Postal  
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Patents, P.O. Box 1450 Alexandria,  
Virginia 22313-1450, on June 1, 2005.

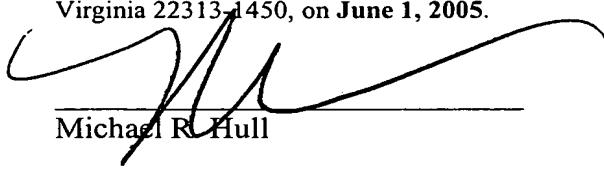
Serial No.: 10/789,055

Filed: February 27, 2004

For: Additive for Photoresist  
Composition for Resist Flow Process

Group Art Unit: 1752

Examiner: Sin J. Lee

  
Michael R. Hull

PRELIMINARY AMENDMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, Virginia 22313-1450

Sir:

Please enter the following preliminary amendment in the above-referenced  
divisional application.

**Amendments to the specification** begin on page 2 of this paper.

**Amendments to the claims** begin on page 3 of this paper.

**Remarks** begin on page 8 of this paper.